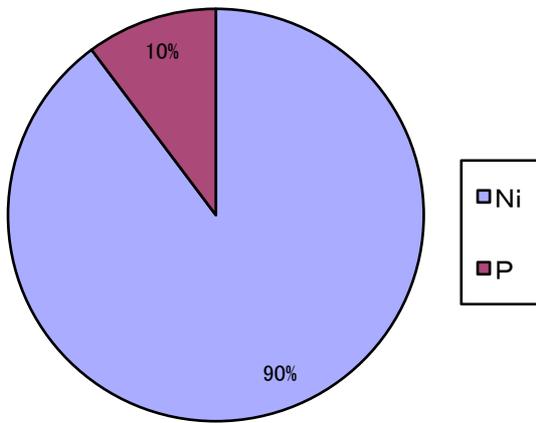
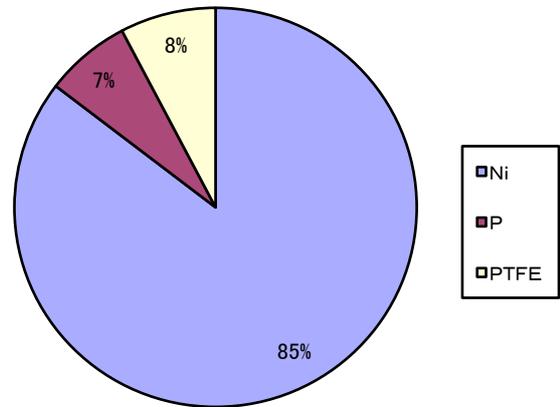


無電解ニッケル系 皮膜組成

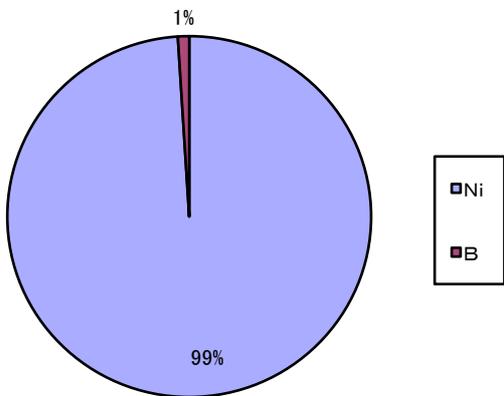
Ni-P



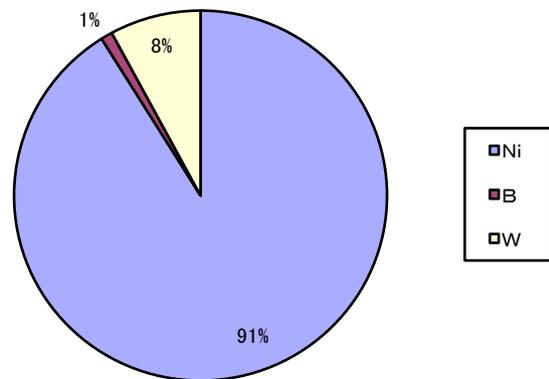
テフロン無電解



Ni-B



W-B-in



皮膜		Ni-P	テフロン	B-in	W-B-in
組成(%)	Ni	89.8	85.4	99.0	91.1
	P	10.2	6.9		
	B			1.0	1.0
	W				7.9
	PTFE		7.7		
組織		非晶質	非晶質	結晶質	結晶質
密度(g/cm ³)		7.81	6.14	8.45	7.86